Atsushi Kobayashi

List of Publications by Year in descending order

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107 papers 1,677 citations

304368 22 h-index 35 g-index

108 all docs

108 docs citations

108 times ranked 1306 citing authors

| # | Article | IF | CITATIONS |
|----|---|-----|-----------|
| 1 | Reduction of Twin Boundary in NbN Films Grown on Annealed AlN. Crystal Growth and Design, 2022, 22, 1720-1723. | 1.4 | 2 |
| 2 | AlN/Al _{0.5} Ga _{0.5} N HEMTs with heavily Si-doped degenerate GaN contacts prepared via pulsed sputtering. Applied Physics Express, 2022, 15, 031002. | 1.1 | 12 |
| 3 | Pulsed Sputtering Preparation of InGaN Multi-Color Cascaded LED Stacks for Large-Area Monolithic Integration of RGB LED Pixels. Crystals, 2022, 12, 499. | 1.0 | 8 |
| 4 | Vertical p-type GaN Schottky barrier diodes with nearly ideal thermionic emission characteristics. Applied Physics Letters, $2021,118,.$ | 1.5 | 12 |
| 5 | Heavily Si-doped pulsed sputtering deposited GaN for tunneling junction contacts in UV-A light emitting diodes. Applied Physics Letters, $2021, 118, \ldots$ | 1.5 | 8 |
| 6 | Pulsed sputtering growth of heavily Si-doped GaN (20 2ì, 1) for tunneling junction contacts on semipolar InGaN (20 2ì, 1) LEDs. Applied Physics Express, 2021, 14, 051011. | 1.1 | 2 |
| 7 | High Electron Mobility AlN on Sapphire (0001) with a Low Dislocation Density Prepared via Sputtering and Highâ€Temperature Annealing. Physica Status Solidi (A) Applications and Materials Science, 2021, 218, 2100074. | 0.8 | 2 |
| 8 | Ultrathin rock-salt type NbN films grown on atomically flat AlN/sapphire substrates. Journal of Crystal Growth, 2021, 572, 126269. | 0.7 | 4 |
| 9 | Combined infrared reflectance and Raman spectroscopy analysis of Si-doping limit of GaN. Applied Physics Letters, 2020, 117, 192103. | 1.5 | 5 |
| 10 | Coherent epitaxial growth of superconducting NbN ultrathin films on AlN by sputtering. Applied Physics Express, 2020, 13, 061006. | 1.1 | 13 |
| 11 | Autonomous growth of NbN nanostructures on atomically flat AlN surfaces. Applied Physics Letters, 2020, 117, . | 1.5 | 9 |
| 12 | Growth of InN ultrathin films on AlN for the application to field-effect transistors. AIP Advances, 2020, 10, 125221. | 0.6 | 1 |
| 13 | Characteristics of unintentionally doped and lightly Si-doped GaN prepared via pulsed sputtering. AIP Advances, 2019, 9, . | 0.6 | 14 |
| 14 | Improving the electron mobility of polycrystalline InN grown on glass substrates using AlN crystalline orientation layers. Journal of Applied Physics, 2019, 126, 075701. | 1.1 | 2 |
| 15 | Wide range doping controllability of p-type GaN films prepared via pulsed sputtering. Applied Physics Letters, 2019, 114, . | 1.5 | 18 |
| 16 | AlN/InAlN thin-film transistors fabricated on glass substrates at room temperature. Scientific Reports, 2019, 9, 6254. | 1.6 | 2 |
| 17 | Operations of hydrogenated diamond metal–oxide–semiconductor field-effect transistors after annealing at 500 °C. Journal Physics D: Applied Physics, 2019, 52, 315104. | 1.3 | 13 |
| 18 | Optical characteristics of highly conductive n-type GaN prepared by pulsed sputtering deposition. Scientific Reports, 2019, 9, 20242. | 1.6 | 17 |

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| 19 | Epitaxial Growth of Thick Polar and Semipolar InN Films on Yttriaâ€5tabilized Zirconia Using Pulsed Sputtering Deposition. Physica Status Solidi (B): Basic Research, 2018, 255, 1700320. | 0.7 | 7 |
| 20 | Growth of Si-doped AlN on sapphire (0001) via pulsed sputtering. APL Materials, 2018, 6, . | 2.2 | 7 |
| 21 | Electrical properties of Si-doped GaN prepared using pulsed sputtering. Applied Physics Letters, 2017, 110, . | 1.5 | 56 |
| 22 | Characterization of GaN films grown on hafnium foils by pulsed sputtering deposition. Physica Status Solidi (A) Applications and Materials Science, 2017, 214, 1700244. | 0.8 | 3 |
| 23 | Epitaxial growth of semipolar InAlN films on yttria-stabilized zirconia. Physica Status Solidi (B): Basic Research, 2017, 254, 1700211. | 0.7 | 1 |
| 24 | Pulsed sputtering epitaxial growth of m-plane InGaN lattice-matched to ZnO. Scientific Reports, 2017, 7, 12820. | 1.6 | 8 |
| 25 | Highly conductive Ge-doped GaN epitaxial layers prepared by pulsed sputtering. Applied Physics Express, 2017, 10, 101002. | 1.1 | 29 |
| 26 | Electron transport properties of degenerate $\langle i \rangle n \langle i \rangle$ -type GaN prepared by pulsed sputtering. APL Materials, 2017, 5, . | 2.2 | 34 |
| 27 | Fabrication of full-color GaN-based light-emitting diodes on nearly lattice-matched flexible metal foils. Scientific Reports, 2017, 7, 2112. | 1.6 | 19 |
| 28 | GaN-Based Light-Emitting Diodes with Graphene Buffers for Their Application to Large-Area Flexible Devices. IEICE Transactions on Electronics, 2017, E100.C, 161-165. | 0.3 | 3 |
| 29 | Epitaxial growth of GaN films on nearly lattice-matched hafnium substrates using a low-temperature growth technique. APL Materials, 2016, 4, . | 2.2 | 8 |
| 30 | High hole mobility p-type GaN with low residual hydrogen concentration prepared by pulsed sputtering. APL Materials, 2016, 4, 086103. | 2.2 | 55 |
| 31 | High-current-density indium nitride ultrathin-film transistors on glass substrates. Applied Physics Letters, 2016, 109, 142104. | 1.5 | 10 |
| 32 | InN thin-film transistors fabricated on polymer sheets using pulsed sputtering deposition at room temperature. Applied Physics Letters, 2016, 109, 032106. | 1.5 | 20 |
| 33 | Epitaxial growth of In-rich InGaN on yttria-stabilized zirconia and its application to metal–insulator–semiconductor field-effect transistors. Journal of Applied Physics, 2016, 120, 085709. | 1.1 | 2 |
| 34 | Fabrication of InGaN thin-film transistors using pulsed sputtering deposition. Scientific Reports, 2016, 6, 29500. | 1.6 | 15 |
| 35 | Feasibility of Fabricating Large-Area Inorganic Crystalline Semiconductor Devices., 2016,, 249-275. | | 0 |
| 36 | Field-effect transistors based on cubic indium nitride. Scientific Reports, 2015, 4, 3951. | 1.6 | 40 |

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| 37 | Investigation of anisotropic wafer bending curvature in a-plane GaN films grown on r-plane sapphire substrates. Journal of Crystal Growth, 2015, 424, 11-13. | 0.7 | 2 |
| 38 | AlGaN/GaN heterostructure prepared on a Si (110) substrate <i>via</i> pulsed sputtering. Applied Physics Letters, 2014, 104, . | 1.5 | 29 |
| 39 | Solidâ€phase epitaxy of InO <i>_x</i> N <i>_y</i> alloys via thermal oxidation of InN films on yttriaâ€stabilized zirconia. Physica Status Solidi - Rapid Research Letters, 2014, 8, 362-366. | 1.2 | 0 |
| 40 | Structural properties of GaN films grown on multilayer graphene films by pulsed sputtering. Applied Physics Express, 2014, 7, 085502. | 1.1 | 30 |
| 41 | Theoretical study of InN growth on Mn-stabilized zirconia (111) substrates. Thin Solid Films, 2014, 551, 110-113. | 0.8 | 0 |
| 42 | Fabrication of full-color InGaN-based light-emitting diodes on amorphous substrates by pulsed sputtering. Scientific Reports, 2014, 4, 5325. | 1.6 | 115 |
| 43 | Theoretical study of the initial stage of InN growth on cubic zirconia (111) substrates. Physica Status Solidi - Rapid Research Letters, 2013, 7, 207-210. | 1.2 | 6 |
| 44 | Band Configuration of SiO ₂ /m-Plane ZnO Heterointerface Correlated with Electrical Properties of Al/SiO ₂ /ZnO Structures. Japanese Journal of Applied Physics, 2013, 52, 011101. | 0.8 | 3 |
| 45 | Theoretical Investigation of the Polarity Determination for <i>c</i> -Plane InN Grown on Yttria-Stabilized Zirconia (111) Substrates with Yttrium Surface Segregation. Applied Physics Express, 2013, 6, 021002. | 1.1 | 4 |
| 46 | Structural Properties ofm-Plane InAlN Films Grown on ZnO Substrates with Room-Temperature GaN Buffer Layers. Applied Physics Express, 2013, 6, 021003. | 1.1 | 7 |
| 47 | Electrical properties of amorphous-Al2O3/single-crystal ZnO heterointerfaces. Applied Physics Letters, 2013, 103, 172101. | 1.5 | 15 |
| 48 | Electron mobility of ultrathin InN on yttria-stabilized zirconia with two-dimensionally grown initial layers. Applied Physics Letters, 2013, 102, 022103. | 1.5 | 17 |
| 49 | Atomic scattering spectroscopy for determination of the polarity of semipolar AlN grown on ZnO. Applied Physics Letters, 2013, 103, . | 1.5 | 5 |
| 50 | Polarity control and growth mode of InN on yttriaâ€stabilized zirconia (111) surfaces. Physica Status Solidi (A) Applications and Materials Science, 2012, 209, 2251-2254. | 0.8 | 7 |
| 51 | Demonstration of enhanced optical polarization for improved deep ultraviolet light extraction in coherently grown semipolar Al0.83Ga0.17N/AlN on ZnO substrates. Applied Physics Letters, 2011, 99, 121906. | 1.5 | 1 |
| 52 | Xâ€ray reciprocal space mapping study on semipolar InAlN films coherently grown on ZnO substrates. Physica Status Solidi - Rapid Research Letters, 2011, 5, 400-402. | 1.2 | 0 |
| 53 | Coherent growth of <i>r</i> à€plane GaN films on ZnO substrates at room temperature. Physica Status Solidi (A) Applications and Materials Science, 2011, 208, 834-837. | 0.8 | 11 |
| 54 | Band offsets of polar and nonpolar GaN/ZnO heterostructures determined by synchrotron radiation photoemission spectroscopy. Physica Status Solidi (B): Basic Research, 2011, 248, 956-959. | 0.7 | 24 |

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| 55 | Fabrication of densely packed arrays of GaN nanostructures on nano-imprinted substrates. Journal of Crystal Growth, 2011, 319, 102-105. | 0.7 | 1 |
| 56 | Growth of group III nitride nanostructures on nano-imprinted sapphire substrates. Thin Solid Films, 2011, 519, 6534-6537. | 0.8 | 0 |
| 57 | Polarity replication across m-plane GaN/ZnO interfaces. Applied Physics Letters, 2011, 99, 181910. | 1.5 | 4 |
| 58 | Dependence on composition of the optical polarization properties of m-plane InxGa1â^'xN commensurately grown on ZnO. Applied Physics Letters, 2011, 99, 061912. | 1.5 | 8 |
| 59 | Polarity Dependence of Structural and Electronic Properties of Al\$_{2}\$O\$_{3}\$/InN Interfaces. Applied Physics Express, 2011, 4, 091002. | 1.1 | 9 |
| 60 | Investigation on the conversion efficiency of InGaN solar cells fabricated on GaN and ZnO substrates. Physica Status Solidi - Rapid Research Letters, 2010, 4, 88-90. | 1.2 | 15 |
| 61 | Optical polarization characteristics of <i>m</i> â€plane InGaN films coherently grown on ZnO substrates. Physica Status Solidi - Rapid Research Letters, 2010, 4, 188-190. | 1.2 | 2 |
| 62 | Structural properties of semipolar AlxGa1â^'xN(\$1ar {1}03\$) films grown on ZnO substrates using room temperature epitaxial buffer layers. Physica Status Solidi (A) Applications and Materials Science, 2010, 207, 2149-2152. | 0.8 | 11 |
| 63 | Structural characteristics of semipolar InN (112 <i>I</i>) films grown on yttria stabilized zirconia substrates. Physica Status Solidi (A) Applications and Materials Science, 2010, 207, 2269-2271. | 0.8 | 4 |
| 64 | Characteristics of Thickm-Plane InGaN Films Grown on ZnO Substrates Using Room Temperature Epitaxial Buffer Layers. Applied Physics Express, 2010, 3, 061001. | 1.1 | 5 |
| 65 | Improvement in the Crystalline Quality of Semipolar AlN(1ar102) Films by Using ZnO Substrates with Self-Organized Nanostripes. Applied Physics Express, 2010, 3, 041002. | 1.1 | 4 |
| 66 | Layer-by-Layer Growth of InAlN Films on ZnO(000ar1) Substrates at Room Temperature. Applied Physics Express, 2010, 3, 021001. | 1.1 | 13 |
| 67 | Structural Characteristics of GaN/InN Heterointerfaces Fabricated at Low Temperatures by Pulsed Laser Deposition. Applied Physics Express, 2010, 3, 021003. | 1.1 | 8 |
| 68 | Electronic structures of c-plane and a-plane AlN/ZnO heterointerfaces determined by synchrotron radiation photoemission spectroscopy. Applied Physics Letters, 2010, 97, 252111. | 1.5 | 12 |
| 69 | Room-Temperature Epitaxial Growth of High-Quality m-Plane InAlN Films on Nearly Lattice-Matched ZnO Substrates. Japanese Journal of Applied Physics, 2010, 49, 070202. | 0.8 | 12 |
| 70 | Characteristics ofm-Plane InN Films Grown on ZnO Substrates at Room Temperature by Pulsed Laser Deposition. Japanese Journal of Applied Physics, 2010, 49, 080202. | 0.8 | 3 |
| 71 | Growth Orientation Control of Semipolar InN Films Using Yttria-Stabilized Zirconia Substrates. Japanese Journal of Applied Physics, 2010, 49, 080204. | 0.8 | 5 |
| 72 | Improvements in Optical Properties of Semipolarr-Plane GaN Films Grown Using Atomically Flat ZnO Substrates and Room-Temperature Epitaxial Buffer Layers. Japanese Journal of Applied Physics, 2010, 49, 100202. | 0.8 | 0 |

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| 73 | Structural and Optical Properties of Nonpolar AlN(1120) Films Grown on ZnO(1120) Substrates with a Room-Temperature GaN Buffer Layer. Japanese Journal of Applied Physics, 2010, 49, 060213. | 0.8 | 6 |
| 74 | Growth of group III nitride films by pulsed electron beam deposition. Journal of Solid State Chemistry, 2009, 182, 1241-1244. | 1.4 | 6 |
| 75 | Epitaxial growth of InN films on lattice-matched EuN buffer layers. Journal of Crystal Growth, 2009, 311, 4483-4485. | 0.7 | 8 |
| 76 | Characteristics of InN grown directly on Al2O3 (0001) substrates by pulsed laser deposition. Journal of Crystal Growth, 2009, 311, 1316-1320. | 0.7 | 15 |
| 77 | Epitaxial growth of high purity cubic InN films on MgO substrates using HfN buffer layers by pulsed laser deposition. Journal of Solid State Chemistry, 2009, 182, 2887-2889. | 1.4 | 5 |
| 78 | Room temperature growth of semipolar AlN (1 $\$$ ar 1 $\$$ 02) films on ZnO (1 $\$$ ar 1 $\$$ 02) substrates by pulsed laser deposition. Physica Status Solidi - Rapid Research Letters, 2009, 3, 58-60. | 1.2 | 13 |
| 79 | Room-temperature epitaxial growth of high-qualitym-plane InGaN films on ZnO substrates. Physica Status Solidi - Rapid Research Letters, 2009, 3, 124-126. | 1.2 | 14 |
| 80 | Room-Temperature Epitaxial Growth of High Quality AlN on SiC by Pulsed Sputtering Deposition. Applied Physics Express, 2009, 2, 011003. | 1.1 | 57 |
| 81 | Lowâ€temperature growth of high quality AlN films on carbon face 6Hâ€SiC. Physica Status Solidi - Rapid Research Letters, 2008, 2, 13-15. | 1.2 | 17 |
| 82 | Growth of a-plane GaN on lattice-matched ZnO substrates using a room-temperature buffer layer. Applied Physics Letters, 2007, 91 , . | 1.5 | 22 |
| 83 | Growth temperature dependence of structural properties of AlN films on ZnO (0001 \hat{A}^-) substrates. Applied Physics Letters, 2007, 90, 141908. | 1.5 | 14 |
| 84 | Epitaxial growth mechanisms of AlN on SiC substrates at room temperature. Applied Physics Letters, 2007, 91, 151903. | 1.5 | 22 |
| 85 | Room temperature epitaxial growth of m-plane GaN on lattice-matched ZnO substrates. Applied Physics Letters, 2007, 90, 041908. | 1.5 | 71 |
| 86 | Epitaxial growth of nonpolar AlN films on ZnO substrates using room temperature grown GaN buffer layers. Applied Physics Letters, 2007, 91, 081915. | 1.5 | 25 |
| 87 | Low temperature epitaxial growth of GaN films on LiGaO2 substrates. Applied Physics Letters, 2007, 90, 211913. | 1.5 | 33 |
| 88 | Structural properties of GaN grown on Zn-face ZnO at room temperature. Journal of Crystal Growth, 2007, 305, 70-73. | 0.7 | 18 |
| 89 | Room temperature epitaxial growth of AlGaN on ZnO by pulsed laser deposition. Applied Physics Letters, 2006, 89, 111918. | 1.5 | 27 |
| 90 | Effects of low-temperature-grown buffers on pulsed-laser deposition of GaN on LiNbO3. Journal of Vacuum Science and Technology A: Vacuum, Surfaces and Films, 2006, 24, 2021-2024. | 0.9 | 4 |

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| 91 | Heteroepitaxial growth of GaN on atomically flat LiTaO3 (0001) using low-temperature AIN buffer layers. Journal of Crystal Growth, 2006, 293, 22-26. | 0.7 | 6 |
| 92 | Epitaxial growth of InN on nearly lattice-matched (Mn,Zn)Fe2O4. Solid State Communications, 2006, 137, 208-211. | 0.9 | 12 |
| 93 | Characteristics of InGaN with High In Concentrations Grown on ZnO at Low Temperatures. Japanese Journal of Applied Physics, 2006, 45, L611-L613. | 0.8 | 15 |
| 94 | Characteristics of Single Crystal ZnO Annealed in a Ceramic ZnO Box and Its Application for Epitaxial Growth of GaN. Japanese Journal of Applied Physics, 2006, 45, 5724-5727. | 0.8 | 24 |
| 95 | Characteristics of GaN/ZrB2Heterointerfaces Prepared by Pulsed Laser Deposition. Japanese Journal of Applied Physics, 2006, 45, 6893-6896. | 0.8 | 8 |
| 96 | Room-Temperature Epitaxial Growth of GaN on Atomically Flat MgAl2O4Substrates by Pulsed-Laser Deposition. Japanese Journal of Applied Physics, 2006, 45, L457-L459. | 0.8 | 15 |
| 97 | Layer-by-Layer Growth of AlN on ZnO(000\$ar{1}\$) Substrates at Room Temperature. Japanese Journal of Applied Physics, 2006, 45, L1139-L1141. | 0.8 | 19 |
| 98 | Room-temperature epitaxial growth of AlN on atomically flat MgAl2O4 substrates. Applied Physics Letters, 2006, 89, 182104. | 1.5 | 18 |
| 99 | Investigation of the initial stage of GaN epitaxial growth on 6H-SiC (0001) at room temperature. Applied Physics Letters, 2006, 89, 031916. | 1.5 | 36 |
| 100 | Polarity control of GaN grown on ZnO (0001 \hat{A}^-) surfaces. Applied Physics Letters, 2006, 88, 181907. | 1.5 | 69 |
| 101 | Low temperature epitaxial growth of In0.25Ga0.75N on lattice-matched ZnO by pulsed laser deposition. Journal of Applied Physics, 2006, 99, 123513. | 1.1 | 61 |
| 102 | Growth temperature dependence of structural properties for single crystalline GaN films on MgAl2O4substrates by pulsed laser deposition. Semiconductor Science and Technology, 2006, 21, 1026-1029. | 1.0 | 10 |
| 103 | GaN heteroepitaxial growth on LiNbO3(0001) step substrates with AlN buffer layers. Physica Status Solidi A, 2005, 202, R145-R147. | 1.7 | 16 |
| 104 | GaN Heteroepitaxial Growth on LiTaO3(0001) Step Substrates by Pulsed Laser Deposition. Japanese Journal of Applied Physics, 2005, 44, L1522-L1524. | 0.8 | 4 |
| 105 | Room-temperature epitaxial growth of GaN on lattice-matched ZrB2 substrates by pulsed-laser deposition. Applied Physics Letters, 2005, 87, 221907. | 1.5 | 57 |
| 106 | Room Temperature Layer by Layer Growth of GaN on Atomically Flat ZnO. Japanese Journal of Applied Physics, 2004, 43, L53-L55. | 0.8 | 76 |
| 107 | Effect of ambient gas on pulsed laser deposition of group III nitrides. Thin Solid Films, 2004, 457, 118-121. | 0.8 | 1 |